Notice of References Cited	Application/Control No. 09/975,257	Applicant(s)/Patent Under Reexamination NARAYANAN ET AL.	
	Examiner David L. Hogans	Art Unit 2813	Page 1 of 1

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	U	Quirk et al., Semiconductor Manufacturing Technology (2001), Prentice Hall, page 477.
	V	Wolf et al., Silicon Processing for the VLSI Era (2000), Lattice Press, Second Edition/Volume 1, pages 299, 300 and 310.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.